Examiner

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Substitute	for form 1449A/PTO		. ,	Application Number	10/712,690
				Filing Date	November 13, 2003
INFO	RMATION DISC	LOS	SURE	First Named Inventor	Chen, et al.
STAT	TEMENT BY AP	PLIC	CANT	Group Art Unit	1784 1763
	:			Examiner Name	Unknown Zervigon
	(Use as many sheets as nec	essary)	1	Attorney Docket Number	AMAT/6766/CPI/L/B/PJS
Sheet	3	of	4	Submission Date	September 29, 2004

Examiner nitials*	Cite No.1	Document Number	_ Put	lication Date	-	Name of Patentee or	Pages, Columns, Lines, Who Relevant Passages or Relev		
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Substi	ute for form 1449A/PTO			Application Number	10/712,690
	•		•	Filing Date	November 13, 2003
INF	ORMATION DISC	CLOS	SURE	First Named Inventor	Chen, et al.
ST	atement by ap	PLI(CANT	Group Art Unit	1794- 1763
		*		Examiner Name	Unknown Zewigon
	(Use as many sheets as ne	cessary) .	Attorney Docket Number	AMAT/6766/CPI/L/B/PJS
She	et 2	of	4	Submission Date	September 29, 2004

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Sheet 1 of 4

Application Number	10/712,690
Filing Date	November 13, 2003
First Named Inventor	Chen, et al.
Group Art Unit	1734 1763
Examiner Name	Unknown Zervigon
Attorney Docket Number	AMAT/6766/CPI/L/B/PJS
Submission Date	September 29, 2004

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		N DISCLOSURE BY APPLICANT		Filing Date	November 13, 2003
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STAT	TEMENT BY AP	PLI(CANT	Group Art Unit	1784-1763
				Examiner Name	Unknown Zervigen
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Sheet	4	of	4	Submission Date	September 29, 2004

		FORE	IGN PATENT	DOCUMENTS		
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Sheet 1 of 7 sheets

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Examiner nitial		Document Number	Issue Date	Applicant(s) Name		Class	Subclass	Filing Date If Appropriate
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PTO Form				·	APP	<i>N</i> 6766	į	10/712,690
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	A8	4,413,022	11/1/1983	SUNTOLA, ET AL		427	255.2	06/21/1979
	A9	4,389,973	06/28/1983	SUNTOLA, ET AL	•	118	725	12/11/1981
	A10	4,058,430	11/15/1977	SUNTOLA, ET AL		156	611	11/25/1975
	A11	20030082296	05/01/2003	ELERS, ET AL.		427	96	09/12/2002
	A12	20030075925	04/24/2003	LINDFORS, ET A	L.	285	367	06/28/2002
	A13	20030075273	04/24/2003	KILPELA, ET AL.		156	345.33	08/14/2002
	A14	20030072975	04/17/2003	SHERO, ET AL.		428	704	09/26/2002
	A15	20030049942	03/13/2003	HAUKKA, ET AL.		438	778	08/22/2002
	A16	20030042630	03/06/2003	BABCOKE, ET AL	-·	261	121.1	09/05/2001
	A17	20030031807	02/13/2003	ELERS, ET AL.		427	569	09/17/2002
	A18	20030013320	01/16/2003	KIM, ET AL.		438	778	05/31/2001
	A19	20030004723	01/02/2003	CHIHARA		704	260	01/29/2002
	A20	20020197402	12/26/2002	CHIANG, ET AL.		427	255.39	08/05/2002
	A21	20020187256	12/12/2002	ELERS, ET AL.		427	99	07/30/2002
	A22	20020182320	12/05/2002	LESKELA, ET AL		427	250	03/15/2002
	A23	20020177282	11/28/2002	SONG		438	300	12/18/2001
1	A24	20020164423	11/07/2002	CHIANG, ET AL.	Ţ	427	255.28	05/03/2002
-	A25	20020164421	11/07/2002	CHIANG, ET AL.		427	248.1	05/03/2002
	A26	20020162506	11/07/2002	SNEH, ET AL.	,	118	715	06/28/2002
7	A27)	20020153722)	10/24/2002	SATTA, ET AL.		438	704	04/15/2002
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw/ine through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

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